Application Serial No. 09/875,501

| Response to March 18, 2004 Final OA

MI22-1741

JUN 1 7 2004

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Assignee Micron Technology, Inc.
Group Art Unit 2815
Examiner E. Ortiz
Attorney's Docket No. MI22-1741
Title: Methods for Forming Wordlines, Transistor Gates, and Conductive Interconnects, and Wordline, Transistor Gate, and Conductive Interconnect Structures

## RESPONSE TO MARCH 18, 2004 FINAL OFFICE ACTION ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION (RCE)

To:

Mail Stop RCE

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

From:

D. Brent Kenady

Tel. 509-624-4276; Fax 509-838-3424

Wells St. John P.S.

601 West First Avenue, Suite 1300

Spokane, WA 99201-3828

Responsive to the Final Office Action dated March 18, 2004, Applicant amends and remarks as follows:

## **AMENDMENTS**

Underlines indicate insertions and strikeouts indicate deletions.